The 8th International Conference on Microelectronics and Plasma Technology | The 9th International Symposium on Functional Materials

Joint International Conference on The 8th ICMAP & The 9th ISFM

January 17-20, 2021 I Online Conference

[TB3] Plasma Sources and Technology III	
Date / Time	January 19 (Tue.), 2021 / 14:30-16:10
Place	Channel B
Session Chair(s)	Li Wang (Ruhr-Univ. Bochum, Germany)

[TB3-1] 14:30-14:50

The Influence of Electron Inertia in Low Pressure Capacitively Coupled Plasmas

Sebastian Wilczek¹, Máté Vass², Ralf Peter Brinkmann¹, Thomas Mussenbrock¹, Zoltán Donkó², Trevor Lafleur³, and Julian Schulze¹

¹Ruhr Univ. Bochum, Germany, ²Wigner Research Centre for Physics, Hungary, ³PlasmaPotential-Physics Consulting and Research, Australia

[TB3-2] 14:50-15:10

Power-Coupling Mode-Change in a High-VHF (162MHz) Multi-Tile, Capacitively Coupled Plasma (CCP) Source

Cleo Harvey¹, Nishant Sirse², Cezar Gaman¹, and Bert Ellingboe¹

¹Dublin City Univ., Ireland, ²Inst. of Engineering and Sci. IPS Academy, India

[TB3-3] Invited 15:10-15:40

Electron Heating and the Magnetic Asymmetry Effect in Magnetized Capacitively Coupled Radio-Frequency Plasmas

Birk Berger, Moritz Oberberg, Li Wang, Dennis Engel, Christian Woelfel, Denis Eremin, Jan Lunze, Ralf Peter Brinkmann, Peter Awakowicz, and Julian Schulze

Ruhr-Univ. Bochum, Germany

[TB3-4] Invited 15:40-16:10

Resonance Phenomena in Radio-Frequency Plasma Sources: From Basic Physics to Technological Significance

Thomas Mussenbrock

Ruhr Univ. Bochum, Germany